

| Application/Control No. | Applicant(s)/Patent under Reexamination | |
|-------------------------|---|--|
| 10/709,179 | CHANG ET AL. | |
| Examiner | Art Unit | |
| Nathan W. Ha | 2814 | |

| SEARCHED | | | |
|-----------------|--------------------------|---------|----------|
| Class | Subclass | Date | Examiner |
| 257 1 438 | 734-74° 780-782 48 | 4/21/05 | Nes ! |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | , |

| INT | INTERFERENCE SEARCHED | | | | |
|-------|-----------------------|------|----------|--|--|
| Class | Subclass | Date | Examiner | | |
| | | | | | |
| | | | | | |
| | | | | | |
| | | | | | |
| | | | | | |

| | DATE | EXMR |
|-----------------|--------|------------|
| See attachment | 4/4/05 | Ì |
| | | |
| | | - <u> </u> |
| | | |
| | | |
| | | |
| | | - |
| | | |
| ·· · | | |